Chart I of 1						<u> </u>
Sheet 1 of 1 FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary) Date Submitted to PTO: April 13, 2001			ATTY DOCKET NO. 032026:0546	SEI	RIAL NO.	09/834791 09/834791 04/13/01
			APPLICANTS Sindo Kou, et al.			
			FILING DATE		GROUP	
		U.S. PA	TENT DOCUMENTS			
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
(4)	4,594,173	6/10/86	Hobgood, et al.			
(m)	4,645,560	2/24/87	Matsumoto, et al.			
(1)	4,654,110	3/31/87	Morrison			
V	4,668,481	5/26/87	Watanabe, et al.			
(4)	4,686,091	8/11/87	Washizuka, et al.			
,57	4,734,267	3/29/88	Kojima			
MA	5,021,118	6/4/91	Kawasaki			
M.)	5,515,810	5/14/96	Yamashita			
K.)	5,851,850	12/22/98	Yanagisawa, et al.			
₹°5	6,143,070	11/7/00	Bliss, et al.	TC		
		FOREIGI	N PATENT DOCUMEN	15		
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT
					Page Etc.)	
	OTHER DOCUM	ENT(S) (Inc William G	luding Author, Title, Dat Pfann, Zone Melting (Bool	k), John Wile	ey & Sons, Inc., 1	966, pp. 199-214.
[1]		I.R.W. Ware, "LEC Growth of Bulk InxGa1-xAs," Report ADA 297039, Defense Technical Information Center, Ft. Belvoir, VA, 1995.				
113		Handbook	of Crystal Growth 2 (Book)	D.T.J. Hur	le, Ed., North-He	olland, Elsevier Science
47.5		Handbook of Crystal Growth 2 (Book), D.T.J. Hurle, Ed., North-Holland, Elsevier Science B.V., 1994, Chapter 2 (Bridgman and Related Growth Techniques), pp. 53-58.				
iv>		M.H. Lin, of Crystal	M.H. Lin, et al., "Dopant Segregation in Crystal Pulling with Bottom Melt Replenishing," J of Crystal Growth, Vol. 142, 1994, pp. 392-396.			
<i>(m)</i>		Kazuo Na Crystals U 217-222.	kajima, et al., "Constant Te Ising the Double Crucible M	mperature Ll lethod," J. o	EC Growth of InC f Crystal Growth,	GaAs Ternary Bulk Vol. 169, 1996, pp.

INC	M.H. Lin, et al., "Czochralski Pulling of InSb Single Crystals from a Molten Zone on a Solid Feed," J. of Crystal Growth, Vol. 193, 1998, pp. 443-445.			
4.5	J. He, et al., "A New Double Crucible Technique for LEC Growth of In-Doped GaAs Crystals," J. of Crystal Growth, Vol. 208, 2000, pp. 42-48.			
<b>f</b> \(\text{\chi}\)	J. He, et al., "Double Crucible LEC Growth of In-Doped GaAs Using Inner Crucibles with a Bottom Tube," J. of Crystal Growth, Vol. 211, 2000, pp. 163-168.			
EXAMINER	DATE CONSIDERED 7/3/2			

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant..